

## EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	72	((light or ray or beam or radiation) near4 (absorb\$4 or adsorb\$4)) near6 (plac\$4 or dispos\$4 or form\$4) near7 ((wafer or substrate or object) adj4 (stage or support\$4 or position\$4))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/24 13:06
L2	3	1 and ((light or ray or radiation or beam) near4 (absorb\$4 or adsorb\$4) near6 ((thermal\$4 or heat\$4 or temperature) adj4 (insulat\$4)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/24 13:09
L3	2	((exposure or \$5lithograph\$4) and ((light or ray or radiation or beam) near4 (absorb\$4 or adsorb\$4) near6 ((thermal\$4 or heat\$4 or temperature) adj4 (insulat\$4))))).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/24 13:10